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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO
09/874,174	06/04/2001	Jiro Kajiwara	A-70092/RMA	7640
75	590 08/12/2004		EXAM	INER
FLEHR HOHBACH TEST			MORGAN, EILEEN P	
ALBRITTON &	& HERBERT LLP			
Suite 3400		ART UNIT	PAPER NUMBER	
Four Embarcadero Center			3723	
San Francisco, CA 94111			DATE MAILED: 08/12/2004	

Please find below and/or attached an Office communication concerning this application or proceeding.

	Application No.	Applicant(s)			
	09/874,174	KAJIWARA ET AL.			
Office Action Summary	Examiner	Art Unit			
	Eileen P Morgan	3723			
The MAILING DATE of this communication a Period for Reply	appears on the cover sheet with the c	orrespondence address			
A SHORTENED STATUTORY PERIOD FOR REF THE MAILING DATE OF THIS COMMUNICATION - Extensions of time may be available under the provisions of 37 CFR after SIX (6) MONTHS from the mailing date of this communication. - If the period for reply specified above is less than thirty (30) days, a result of the period for reply is specified above, the maximum statutory perion of the period for reply within the set or extended period for reply will, by stated any reply received by the Office later than three months after the material patent term adjustment. See 37 CFR 1.704(b).	N. 1.136(a). In no event, however, may a reply be ting the statutory minimum of thirty (30) day and will expire SIX (6) MONTHS from tute, cause the application to become ABANDONE	nely filed /s will be considered timely. If the mailing date of this communication. ED (35 U.S.C. § 133).			
Status					
1) Responsive to communication(s) filed on 04	June 2001				
,	his action is non-final.				
3) Since this application is in condition for allow					
closed in accordance with the practice unde	r <i>Ex par</i> re <i>Quayle</i> , 1935 C.D. 11, 4:	53 O.G. 213.			
Disposition of Claims					
4)	rawn from consideration.				
Application Papers					
9) The specification is objected to by the Examination The drawing(s) filed on is/are: a) and applicant may not request that any objection to the	ccepted or b) objected to by the he drawing(s) be held in abeyance. Se	e 37 CFR 1.85(a).			
Replacement drawing sheet(s) including the corr					
Priority under 35 U.S.C. § 119					
12) Acknowledgment is made of a claim for forei a) All b) Some * c) None of: 1. Certified copies of the priority docume 2. Certified copies of the priority docume 3. Copies of the certified copies of the priority docume application from the International Bure * See the attached detailed Office action for a least company content of the priority documents.	ents have been received. ents have been received in Applicat riority documents have been receive eau (PCT Rule 17.2(a)).	ion No ed in this National Stage			
Attachment(s)					
 Notice of References Cited (PTO-892) Notice of Draftsperson's Patent Drawing Review (PTO-948) Information Disclosure Statement(s) (PTO-1449 or PTO/SB/Paper No(s)/Mail Date 	4) Interview Summary Paper No(s)/Mail D 5) Notice of Informal F 6) Other:				

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DETAILED ACTION

Claim Rejections - 35 USC § 112

The following is a quotation of the second paragraph of 35 U.S.C. 112:

The specification shall conclude with one or more claims particularly pointing out and distinctly claiming the subject matter which the applicant regards as his invention.

Claim 8 rejected under 35 U.S.C. 112, second paragraph, as being indefinite for failing to particularly point out and distinctly claim the subject matter which applicant regards as the invention.

Claim 8 depends on claim 9.

Claim Rejections - 35 USC § 102

The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless -

- (b) the invention was patented or described in a printed publication in this or a foreign country or in public use or on sale in this country, more than one year prior to the date of application for patent in the United States.
- (e) the invention was described in (1) an application for patent, published under section 122(b), by another filed in the United States before the invention by the applicant for patent or (2) a patent granted on an application for patent by another filed in the United States before the invention by the applicant for patent, except that an international application filed under the treaty defined in section 351(a) shall have the effects for purposes of this subsection of an application filed in the United States only if the international application designated the United States and was published under Article 21(2) of such treaty in the English language.

Claims 1-3,5,7-12, 32,33,41 rejected under 35 U.S.C. 102(b) as being anticipated by Japan 10-217108.

Japan '108 discloses a retaining ring of a subcarrier for holding a wafer during polishing comprising an annular groove disposed in the bottom of the

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retaining ring. The distance of the groove from the edge, and the depth and width based on magnitude of a force is incidental.

Claims 1-3,5,7-13, 32,33,41 rejected under 35 U.S.C. 102(b) as being anticipated by Japan 11-333712.

Japan '712 discloses a retaining ring of a subcarrier for holding a wafer during polishing comprising concentric annular grooves disposed in the bottom of the retaining ring. The distance of the groove from the edge, and the depth and width based on magnitude of a force is incidental.

Claims 1-3,5,7-12,14, 32,33,41 rejected under 35 U.S.C. 102(e) as being anticipated by Glashauser-6,419,567.

Glashauser discloses a retaining ring of a subcarrier for holding a wafer during polishing comprising an annular groove disposed in the bottom of the retaining ring. The distance of the groove from the edge, and the depth and width based on magnitude of a force is incidental.

Claim Rejections - 35 USC § 103

The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

(a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.

Claims 1-3,5,7-12, 15-20,29-33,41 rejected under 35 U.S.C. 103(a) as being unpatentable over Japan '108, alone.

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Japan '108 discloses a retaining ring of a subcarrier for holding a wafer during polishing comprising an annular groove disposed in the bottom of the retaining ring. The distance of the groove from the edge, and the depth and width based on magnitude of a force is incidental and would have been a matter of obvious design choice. The selection of the material of the retaining ring would have been an obvious design expedient dependent on machining parameters.

Claims 1-3,5,7-13, 15-20,25,26, 29-33,41 rejected under 35 U.S.C. 103(a) as being unpatentable over Japan '712,alone.

Japan '712 discloses a retaining ring of a subcarrier for holding a wafer during polishing comprising concentric annular grooves disposed in the bottom of the retaining ring. The distance of the groove from the edge, and the depth and width based on magnitude of a force is incidental and would have been a matter of obvious design choice. The selection of the material of the retaining ring would have been an obvious design expedient dependent on machining parameters.

Claim1-3,5,7-12,14-20,27-33,41 rejected under 35 U.S.C. 103(a) as being unpatentable over Glashauser '567, alone.

Glashauser discloses a retaining ring of a subcarrier for holding a wafer during polishing comprising an annular groove disposed in the bottom of the retaining ring. The distance of the groove from the edge, and the depth and width based on magnitude of a force is incidental and would have been a matter of obvious design choice. The selection of the material of the retaining ring

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would have been an obvious design expedient dependent on machining parameters.

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Eileen P Morgan whose telephone number is 703.308.1743.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Joseph Hail can be reached on 703.308.2687. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

ΕM

August 6, 2004

EILEEN P. MORGAN PRIMARY EXAMINER